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Development of a High Photon Flux XUV Laser Source for Spectroscopy of Highly-Charged Ions at FAIR

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Primary authors: Mr KIRSCHE, Alexander (Institute of Applied Physics); ROTHHARDT, Jan (Helmholtz Institute Jena); Prof. LIMPert, Jens (Friedrich-Schiller-University Jena); Mr TSCHERNAJEV, Maxim (Helmholtz Institute Jena & Institute of Applied Physics); Mr KLAS, Robert (Helmholtz Institute Jena & Institute of Applied Physics); SCHIPPERS, Stefan (Justus-Liebig-University Giessen, Germany); Dr STÖHLKER, T. (GSI, Darmstadt, Germany); HILBERT, vinzenz (Institute of Applied Physics, Albert-Einstein-Straße 15, 07745 Jena, Germany)

Presenter: HILBERT, vinzenz (Institute of Applied Physics, Albert-Einstein-Straße 15, 07745 Jena, Germany)